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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/775,653	02/05/2001	Yuuichi Tachino	1076.1063 (JDH)	9294	
21171	7590 04/04/2003				
STAAS & HALSEY LLP			EXAMINER		
700 11TH STF SUITE 500	•		CROWELL,	ANNA M	
WASHINGTON, DC 20001			ART UNIT	PAPER NUMBER	
			1763		
	•		DATE MAILED: 04/04/2003	DATE MAILED: 04/04/2003	

Please find below and/or attached an Office communication concerning this application or proceeding.

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·		Application No.	Applicant(s)				
Office Action Summary		09/775,653	TACHINO ET AL.				
		Examiner	Art Unit	<del>- ,</del>			
		Michelle Crowell	1763				
Period fo	The MAILING DATE of this communication app or Reply	ears on the cover sheet wi	th the correspondence address	<b>;</b>			
THE N - Exter after - If the - If NO - Failui - Any n	ORTENED STATUTORY PERIOD FOR REPLY MAILING DATE OF THIS COMMUNICATION. sions of time may be available under the provisions of 37 CFR 1.13 SIX (6) MONTHS from the mailing date of this communication. period for reply specified above is less than thirty (30) days, a reply period for reply is specified above, the maximum statutory period were to reply within the set or extended period for reply will, by statute, eply received by the Office later than three months after the mailing and patent term adjustment. See 37 CFR 1.704(b).	86(a). In no event, however, may a rewithin the statutory minimum of thirty ill apply and will expire SIX (6) MON cause the application to become AB.	eply be timely filed  (30) days will be considered timely.  FHS from the mailing date of this commun  ANDONED (35 U.S.C. § 133).	ication.			
1)⊠	Responsive to communication(s) filed on 24 J	<u>anuary 2003</u> .					
2a)⊠	This action is <b>FINAL</b> . 2b) This	s action is non-final.					
3)□	Since this application is in condition for allowardsed in accordance with the practice under			rits is			
•	on of Claims						
•	Claim(s) <u>2,3,7,10,11,13,14,17,18 and 21-23</u> is		ation.				
	4a) Of the above claim(s) is/are withdrav	vn from consideration.					
·	Claim(s) is/are allowed.						
·	Claim(s) <u>2,3,7,10,11,13,14,17,18 and 21- 23</u> is/are rejected.						
· ·	Claim(s) is/are objected to.						
•	Claim(s) are subject to restriction and/or on Papers	election requirement.					
• •	The specification is objected to by the Examine	•					
´ <u> </u>	The drawing(s) filed on is/are: a)☐ accep		ne Examiner				
,	Applicant may not request that any objection to the	•					
11) 🔲 🛚	The proposed drawing correction filed on	= : :					
	If approved, corrected drawings are required in rep						
12) 🔲 🗆	The oath or declaration is objected to by the Exa	aminer.					
Priority u	nder 35 U.S.C. §§ 119 and 120						
13)	Acknowledgment is made of a claim for foreign	priority under 35 U.S.C. §	119(a)-(d) or (f).				
a)[	☐ All b) ☐ Some * c) ☐ None of:						
	1. Certified copies of the priority documents	s have been received.					
	2. Certified copies of the priority documents have been received in Application No						
	3. Copies of the certified copies of the prior application from the International Buree the attached detailed Office action for a list	eau (PCT Rule 17.2(a)).		е			
14) <u></u> A	cknowledgment is made of a claim for domestic	priority under 35 U.S.C.	§ 119(e) (to a provisional appl	ication).			
	)  The translation of the foreign language pro	• •					
Attachment	_	•					
2) Notice	e of References Cited (PTO-892) e of Draftsperson's Patent Drawing Review (PTO-948) nation Disclosure Statement(s) (PTO-1449) Paper No(s) 7	5) Notice of la	Summary (PTO-413) Paper No(s) nformal Patent Application (PTO-152)				
S. Patent and Tr	ademark Office						

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, a.,

#### **DETAILED ACTION**

# Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 2. Claims 2, 3, 7, 11, 13, 14, 18, and 23 rejected under 35 U.S.C. 102(b) as being anticipated by Tepman et al.

Referring to Figures 5 and 6, column 6, lines 15-24, and column 7, lines 35-65, Tepman discloses a plasma reactor 30 which performs etching. The reactor 30 includes a dielectric reactor ceiling 100 (reaction tube), an RF coil 150 (high frequency coil antenna) with multiple windings 152, 154, and 156 (winding portions), and a connecting rod 310 (drive mechanism). The reactor ceiling 100 may be cylindrically shaped or other geometries suitable for plasma processing (col. 5, lines 65-67). The RF coil 150 is mounted on a coil support 270 (intermediate segment which is sloped or inclined), and the coil support 270 connects the various windings in series. In addition, the coil support 270 is located closer to an outer peripheral surface of the reactor 240 (reaction tube) than the RF coil 150. The RF coil 150 is connected to ground at winding 152 and connected to a power supply source at 170. Both the RF coil 150 and the coil support 270 rotate around the reactor ceiling 100 by means of a connecting rod 310 (drive mechanism). When the RF coil is rotated around the reactor ceiling, the majority of the inner surface of the reactor vessel is cleaned (etched).

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4.

# Regarding Claims 2 and 13

Claims 2 and 13 recite the limitation "when performing plasma etching". This limitation refers to the intended use (etching) of the plasma apparatus which has no significance in the patentability of apparatus claims. A claim containing a "recitation with respect to the manner in which a claimed apparatus is intended to be employed does not differentiate the claimed apparatus from a prior art apparatus" if the prior art apparatus teaches all the structural limitations of the claim. Ex parte Thiabault, 164 USPQ 666, 667 (Bd. App. 1969).

3. Claims 10 and 17 are rejected under 35 U.S.C. 103(a) as being unpatentable over Tepman et al. (U.S. 5,879,575) in view of Okumura et al. (U.S. 5,888,413).

Tepman in view of Forster fails to teach a controller.

Referring to Figures 1 and 17, column 4, line 65-column 5, line5, and column 10, lines 5-10, Okumura teaches that it is known to use a controller 100 to control the rotational speed of a coil 1 by controlling the stepping motor 3 (rotary actuator-drive mechanism). The coil 1 is connected to a stepping motor 3 via rotary shaft 4. By controlling the rotational speed of the coil, better control of the plasma density is achieved. Therefore, it would have been obvious to one of ordinary skill in the art at the time of the invention to provide the rotational drive mechanism of Tepman with the controller as taught by Okumura. This would provide better control of the plasma density inside the chamber.

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Claims 21 and 22 are rejected under 35 U.S.C. 103(a) as being unpatentable over Tepman 4. et al. (U.S. 5,879,575) in view of Takada et al. (U.S. 5,525,379).

Tepman in view of Forster fails to teach the sloped segment wound around approximately one fourth the reaction tube and the winding wound around three fourths the reaction tube.

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Referring to Figure 5a and column 5, lines 28-49, Takada shows a antenna 22 which has a coil antenna configuration including a sloped segment and two windings. The sloped segment is wound around approximately one fourth of a circumference of a peripheral surface of the reaction tube 21. Each winding is wound around approximately three-fourths of the circumference of the peripheral surface of the reaction tube. The advantage of this coil antenna configuration is that prevention of stress when forming a film is enhanced, and therefore it is possible to form films at a high speed. Thus, it would have been obvious to one of ordinary skill in the art at the time of the invention to modify the coil antenna of Tepman with the coil antenna as shown by Takada. This coil antenna configuration lowers the stress of the film formed.

## Response to Arguments

5. Applicant's arguments with respect to claims 2, 3, 7, 10, 11, 13, 14, 17, 18, and 21-23 have been considered but are most in view of the new ground(s) of rejection.

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### Conclusion

6. Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Michelle Crowell whose telephone number is (703) 305-1956. The examiner can normally be reached on M-F (8:00 - 4:30).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Gregory Mills can be reached on (703) 308-1633. The fax phone numbers for the organization where this application or proceeding is assigned are (703) 872-9310 for regular communications and (703) 872-9311 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0661.

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